

Article

# The FLASH Facility: Advanced Options for FLASH2 and Future Perspectives

Bart Faatz<sup>1</sup>, Markus Braune<sup>1</sup>, Olaf Hensler<sup>1</sup>, Katja Honkavaara<sup>1</sup>, Raimund Kammering<sup>1</sup>, Marion Kuhlmann<sup>1</sup>, Elke Ploenjes<sup>1</sup>, Juliane Roensch-Schulenburg<sup>1</sup>, Evgeny Schneidmiller<sup>1</sup>, Siegfried Schreiber<sup>1</sup> , Kai Tiedtke<sup>1</sup>, Markus Tischer<sup>1</sup>, Rolf Treusch<sup>1</sup>, Mathias Vogt<sup>1</sup>, Wilfried Wurth<sup>1,2,\*</sup>, Mikhail Yurkov<sup>1</sup> and Johann Zemella<sup>1</sup>

<sup>1</sup> Deutsches Elektronen-Synchrotron (DESY), 22607 Hamburg, Germany; Bart.faatz@desy.de (B.F.); Markus.braune@desy.de (M.B.); Olaf.hensler@desy.de (O.F.); katja.honkavaara@desy.de (K.H.); raimund.kammering@desy.de (R.K.); marion.kuhlmann@desy.de (M.K.); elke.ploenjes@desy.de (E.P.); juliane.roensch@desy.de (J.R.-S.); evgeny.schneidmiller@desy.de (E.S.); siegfried.schreiber@desy.de (S.S.); kai.tiedtke@desy.de (K.T.); markus.tischer@desy.de (M.T.); rolf.treusch@desy.de (R.T.); mathias.vogt@desy.de (M.V.); mikhail.yurkov@desy.de (M.Y.); johann.zemella@desy.de (J.Z.)

<sup>2</sup> Physics Department and Center for Free-Electron Laser Science, University of Hamburg, 22761 Hamburg, Germany

\* Correspondence: wilfried.wurth@desy.de

Academic Editor: Kiyoshi Ueda

Received: 10 September 2017; Accepted: 16 October 2017; Published: 28 October 2017

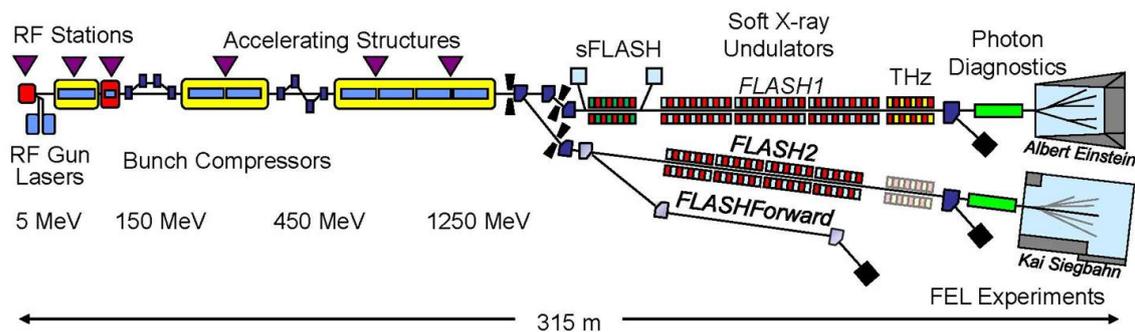
**Abstract:** Since 2016, the two free-electron laser (FEL) lines FLASH1 and FLASH2 have been run simultaneously for users at DESY in Hamburg. With the installation of variable gap undulators in the new FLASH2 FEL line, many new possibilities have opened up in terms of photon parameters for experiments. What has been tested so far is post-saturation tapering, reverse tapering, harmonic lasing, harmonic lasing self-seeding and two-color lasing. At the moment, we are working on concepts to enhance the capabilities of the FLASH facility even further. A major part of the upgrade plans, known as FLASH2020, will involve the exchange of the fixed gap undulators in FLASH1 and the implementation of a new flexible undulator scheme aimed at providing coherent radiation for multi-color experiments over a broad wavelength range. The recent achievements in FLASH2 and the current status of plans for the further development of the facility are presented.

**Keywords:** free-electron lasers, variable gap undulators, tapering, harmonic lasing, frequency doubling

## 1. Introduction

FLASH began operation for experiments in the extended ultraviolet (XUV) and soft X-ray regime in summer 2005 as the world's first short-wavelength free-electron laser (FEL) facility [1–3]. Due to its superconducting accelerator technology, FLASH is currently the only high-repetition rate XUV and soft X-ray FEL which can deliver up to 8000 photon pulses per second for experiments, while normal conducting FELs typically run at rates between 10 and 120 pulses per second. Since 2016, after the installation and commissioning of a second undulator line, it has been possible for two experiments to receive a beam simultaneously [4,5]. Both FEL lines FLASH1 and FLASH2 (see Figure 1 for a layout of the facility) are currently run in self-amplified stimulated emission (SASE) mode. The superconducting linac of FLASH is operated in a so-called burst mode and can deliver up to 800 electron bunches in a train with a bunch-to-bunch separation of 1  $\mu$ s and a 10 Hz repetition rate of the bunchtrains. Using two independent photocathode lasers for FLASH1 and FLASH2, the number of bunches from a bunchtrain as well as the intra-train bunch separation going to either of the two FEL lines can be chosen freely,

taking into account that 20 to 50  $\mu\text{s}$  are needed to switch bunches between FLASH1 and FLASH2 [4]. The independent photocathode lasers also ensure that the bunch charge can be adjusted individually for the two FEL lines. In combination with fast radio frequency (RF) changes in the time window needed for switching, this enables different compression schemes and hence different pulse durations for user experiments in FLASH1 and FLASH2 [4]. The most important parameters for FLASH2 are shown in the Table 1. While the original FLASH1 FEL line is equipped with fixed gap undulators, which requires a change in the electron beam energy to change the photon energy, the new FLASH2 FEL line has variable gap undulators, which allow for scanning of the photon energy. Furthermore, the possibility for tuning the undulators in FLASH2 has opened up the opportunity to implement and test a variety of novel lasing schemes. First results and future plans will be discussed below.



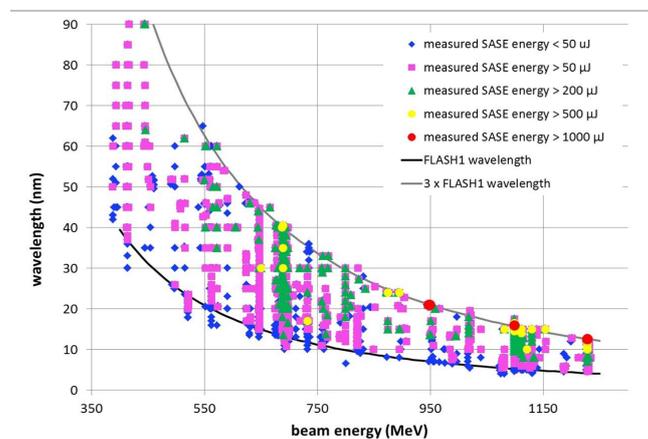
**Figure 1.** Schematic layout of the FLASH facility. The electron gun is on the left, and the experimental halls are on the right. Behind the last accelerating module the beam is switched between FLASH1, which is the original undulator line, and FLASH2, which has been in operation since 2015. Also shown is sFLASH, the seeding R&D setup in FLASH1 [6] and FLASHForward [7], which is a plasma wakefield experiment in the FLASH3 beamline under construction planned to start operation at the end of 2017. FEL: free-electron laser.

**Table 1.** Parameters for FLASH2. SASE: self-amplified stimulated emission.

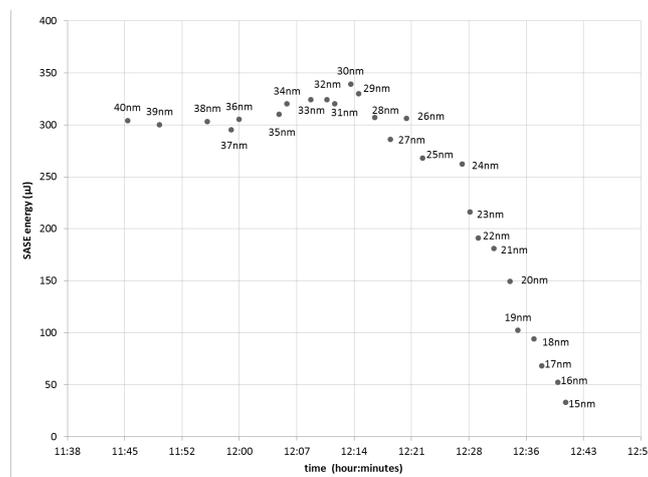
Electron Beam	Value
Energy range	0.45–1.2 GeV
Peak current	$\leq 2.5$ kA
Bunch charge	0.02–1 nC
Normalized emittance	1.4 mm mrad
Energy spread	0.5 MeV
Average $\beta$ -function	6 m
Rep. rate	10 Hz
Bunch separation	1–25 $\mu\text{s}$
Undulator	Value
Period	31.4 mm
$K_{rms}$	0.5–2
Segment length	2.5 m
Number of segments	12
Photon Beam SASE	Value
Wavelength range (fundamental)	4–90 nm
Average single pulse energy	up to 1 mJ
Pulse duration (FWHM)	10–200 fs
Spectral width (FWHM)	$\approx 0.5$ –2%
Peak brilliance	$10^{28}$ – $10^{31}$ B

## 2. Fast Wavelength Scans

The advantage of variable gap undulators in terms of enhanced flexibility regarding wavelength tunability is demonstrated in Figures 2 and 3. While the setup of FLASH1 for SASE for a new user experiment at a specific wavelength takes up to several hours because of the required electron beam energy change (with FLASH1 undulators being fixed-gap), setup of FLASH2 can normally be done within one hour or less, depending on the wavelength requested compared to the one at FLASH1. As a consequence, the time it takes for the initial setup of FLASH2 which is done combined with FLASH1, is almost completely determined by the FLASH1 setup time. After that, any change in wavelength and pulse pattern for FLASH2 can be done in a matter of minutes. The longest wavelength that can be reached is produced when the undulators are closed and is given by approximately three times the FLASH1 wavelength for the specific electron beam energy. The minimum FLASH2 wavelength in normal SASE operation depends on the electron beam energy and beam quality, but it is always less than or equal to the FLASH1 wavelength. Therefore, factor of 3 wavelength tunability can be offered at any time. For lower electron beam energies, one can even go significantly beyond that, with up to factor of 4 tunability at lower energies.



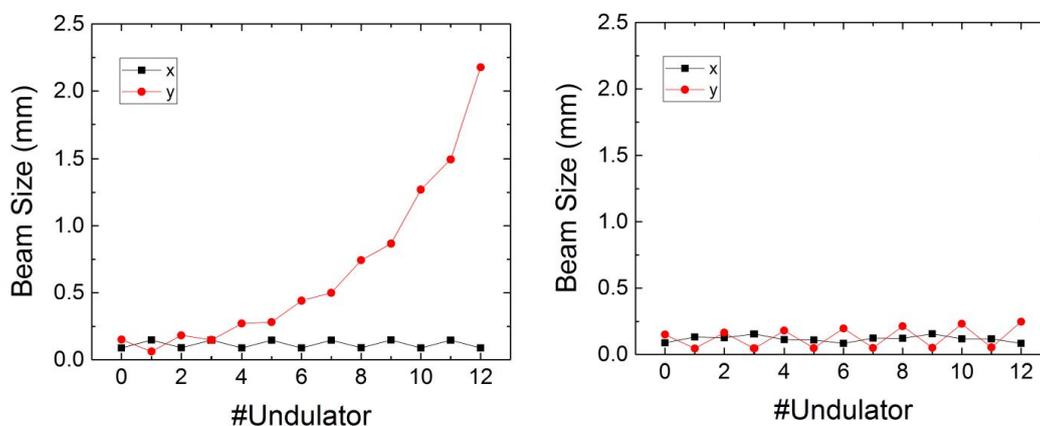
**Figure 2.** Wavelength tunability of FLASH2 for specific electron beam energies. The different symbols and colors refer to the achieved photon pulse energies. The upper and lower limits are given by three times the FLASH1 wavelength as a maximum (for a closed undulator gap) and the FLASH1 wavelength as a minimum.



**Figure 3.** Fast wavelength scan at FLASH2 performed while FLASH1 delivered the beam to users at 13.5 nm (electron beam energy 699 MeV). This scan was performed with standard undulator optics (see below).

Figure 3 shows a fast wavelength scan. In principle, the only action needed to decrease the wavelength is opening of the undulators. In practice, minor orbit corrections of the electron beam are necessary. The online, non-invasive measurement of crucial photon parameters including wavelength, intensity, and beam position need only a few seconds to average before these values are available again. Hence, setting a new wavelength takes only minutes as long as the wavelength change is moderate. In particular, scanning across a photoabsorption resonance is almost as easy as at a storage ring.

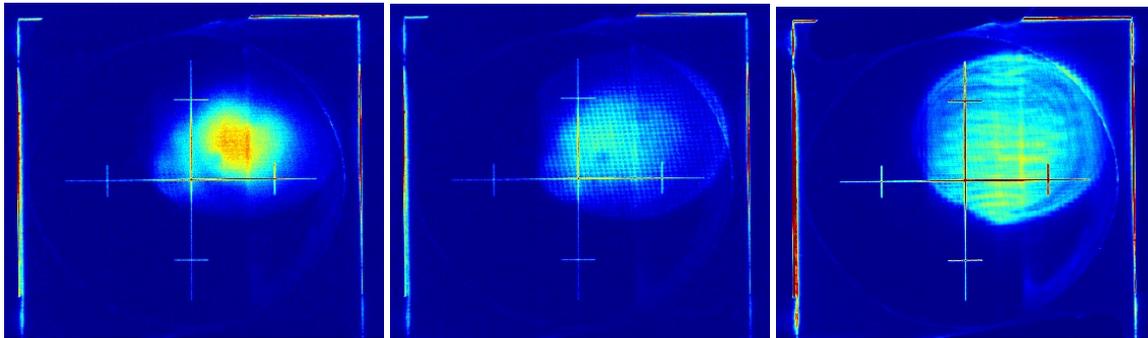
For large wavelength changes, the setup is still fast, but needs further adjustments concerning electron beam optics. For electron beam energies, at which FLASH is operated, the undulator focusing can be rather strong when the undulators are closed. In extreme cases, as shown in simulations in Figure 4, the focusing becomes so strong that the beam size along the undulator grows and leads to losses unless the focusing is adjusted. Even if these losses would not trigger the machine protection system and consequently switch off the beam, the growing beam size would pose a problem. In this case, the last undulators would no longer contribute to the FEL amplification process, resulting in lower pulse energy. Furthermore, the source point would be no longer in the last undulator, forcing the experiment to either move the instrument or adapt the focusing, assuming that either is possible. Neither solution is straightforward and they can only be performed once the saturation source point is remeasured. At FLASH2, we therefore now adjust the focusing automatically, as shown in the simulations in the right picture of Figure 4. Theoretically, this would also require a rematching of the electron beam at the undulator entrance, which can be calculated in special and straightforward cases, but not easily in general. With more exotic schemes, such as two-color lasing or any fast switching schemes, that will become more important in the future, because a mismatch can in general no longer be avoided. However, as can also be seen in Figure 4, for now even without rematching, the result of the simple adjustment procedure used is more than sufficient.



**Figure 4.** Simulated beam size (in mm) along the undulator without automatic adjustment (**left**) and including adjusted focusing to compensate for the additional undulator focusing (**right**) for a beam energy of 380 MeV and an undulator  $K_{rms} = 2$ .

The results in Figure 4 are from simulations as mentioned. However, the effect of the automatic optics adjustment can be clearly seen experimentally, as shown in Figure 5, for the same beam energy of 380 MeV as in the simulations. The figure shows the photon beam on a YAG (Yttrium aluminium garnet)-screen for different wavelengths from 50 to 150 nm in a single scan, with automatic optics adjustment switched on, but no other parameters touched during this scan (The interference pattern visible on the screen is caused by a mesh, which is inserted in the photon beam upstream of one of the photon detectors. Furthermore, the YAG screen already shows some beam-induced damage, which makes the beam quality seem poorer than it actually is). In contrast, without adjusting the optics, the spot would look identical at  $\lambda = 50$  nm, where the undulator focusing is not yet important, but at  $\lambda = 85$  nm, the beam would have already become extremely large and the radiation power

would have dropped. For wavelengths longer than  $\lambda = 85$  nm, the beam losses in the undulator would have exceeded the alarm threshold of the machine protection system and as a result, the beam would have been switched off. Including adjusted optics, one can continue to close the gaps down to 9 mm, corresponding to  $\lambda = 150$  nm without any problem. It is also clear from Figure 5 that further improvement is still needed. Because no beam-based alignment was performed prior to this experiment, a small movement of the center of the beam is visible.



**Figure 5.** Photon spotsize for 50 (left), 85 (middle) and 150 nm (right) wavelength, 15 m downstream of the undulator with automatic optics adjustment in the undulator switched on. Without adjustment, the undulators cannot be closed to produce wavelengths longer than 85 nm because of beam loss.

However, even given the need for further beam optics automation, first user experiments where the photon energy has been scanned across a resonance within minutes have already demonstrated the great advantages of tunable undulators for experiments at FLASH.

### 3. New Operation Modes

The variable gap undulators not only allow fast wavelength scans but also enable novel operation modes, such as advanced tapering schemes, frequency doubling, two-color operation, and harmonic lasing self-seeding. With optimized undulator tapering, photon pulse energies up to 1 mJ have been demonstrated at FLASH2 [8]. A particularly interesting option in this respect is reverse tapering [9,10]. In combination with a harmonic afterburner for circular polarization currently under design this should in the future allow experiments with variable polarization at photon energies beyond the water window at FLASH2. Tuning the FLASH2 undulators individually it is also possible to push the photon energy range of FLASH beyond the current limit of 300 eV in the fundamental.

Setting the first part of the undulator section to twice the final wavelength in a frequency doubling scheme it has been shown that the photon energy range of FLASH2 can be extended up to 400 eV with stable pulse energies of a few  $\mu$ J, significantly higher than what has been achieved when the full undulator section is set to the final wavelength at the same electron energy [11]. Another interesting option is harmonic lasing self-seeding (HLSS) which had been proposed a while ago [12] as a method to reach higher photon energies with increased brightness. With FLASH2, HLSS was recently demonstrated for the first time experimentally and the theoretical predictions were confirmed [13]. In the following some results for the different schemes will be presented.

Harmonic lasing self-seeding (HLSS), while proposed some time ago, could never be tested at FLASH1 with its fixed gap undulators. HLSS requires the setting of the first part of the undulator section to a sub-harmonic ( $h\lambda$ ) of the final wavelength which is schematically shown in Figure 6. As can be seen in Figure 7, saturation is reached earlier with HLSS than with conventional SASE. This is clear from the higher power and the reduction in fluctuations when saturation is reached. More importantly, the bandwidth is also reduced and therefore the brightness is higher, as shown in Figure 8. Due to the limitations of FLASH2, which was originally not built with this concept in mind, one can only go to the second or third harmonic of the wavelength selected for the first part of the undulator,

but in principle, higher harmonics could be considered when an FEL line is specifically designed for efficient use of the HLSS scheme.

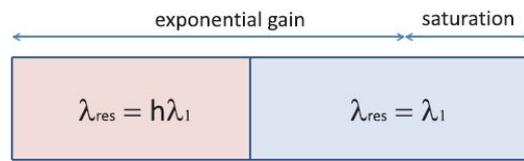


Figure 6. Conceptual scheme of a harmonic lasing self-seeded (HLSS) FEL.

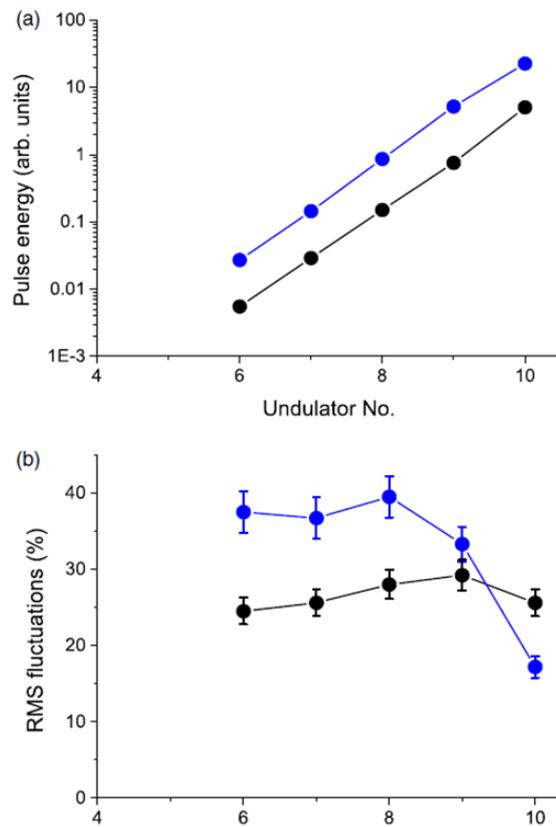


Figure 7. Growth of pulse energy (a) and fluctuations (b) along the undulator for SASE (black) and HLSS (blue). In the HLSS experiment the first four undulators were set to 33 nm and the next six undulators to 11 nm, while in the SASE case all ten undulators modules were set to 11 nm.

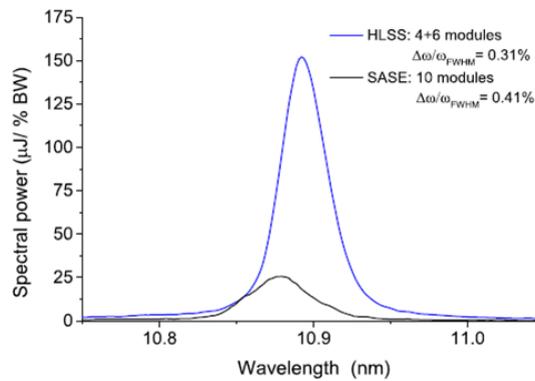


Figure 8. Spectral bandwidth for SASE and HLSS in the same experiment.

The wavelength limits can be pushed at FLASH2 by tuning the undulator sections individually as shown in the frequency doubler scheme in Figure 9. Given the maximum electron beam energy of FLASH of 1.25 GeV, radiation in the water window at 4 nm can only be reached with the present FLASH2 undulator design and normal SASE operation with all undulators set to the same wavelength using the complete undulator length. Going to shorter wavelengths, the SASE intensity drops fast, because saturation is no longer reached. In addition, the SASE fluctuations increase for the same reason. Compared to this, the radiation intensity is clearly higher than it would be without a frequency doubler scheme, as can be seen in Figure 10. In the experiment, first the fundamental at frequency  $\omega$  is tuned for maximum SASE gain in the uniform undulator. Analysis of the gain curve and fluctuations of the radiation pulse energy allows for determination of the optimum length of the  $\omega$ -section. Then, the remaining sections are tuned to the frequency  $2\omega$ , and after adjustment of the phase shifters and electron beam orbit, the frequency doubler starts to generate radiation at the second harmonic.



Figure 9. Scheme of frequency doubler operation.

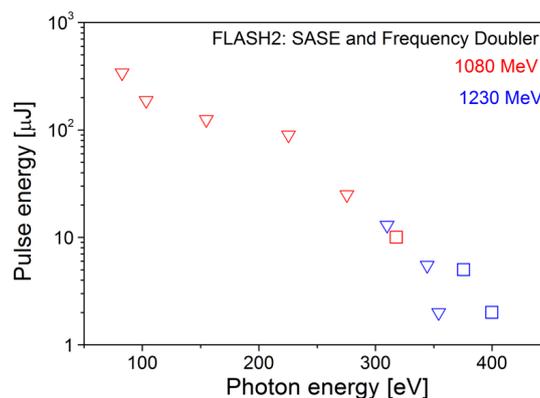
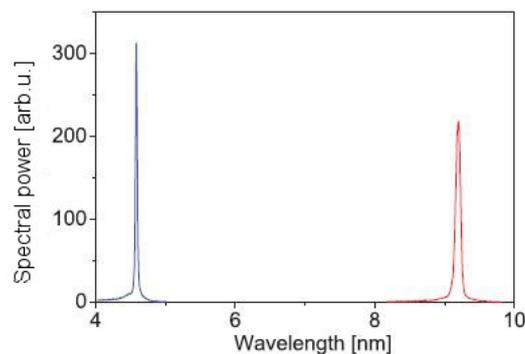


Figure 10. Setting the first part of the undulator to twice the final wavelength (squares), the final wavelength that can be reached with reasonable pulse energy is much shorter and has more stable intensity than with setting all undulators to the same resonant wavelength (triangles).

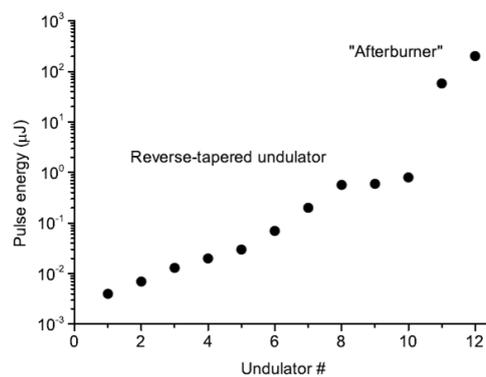
The same scheme can also be used for two-color operation of the FEL line. In Figure 11 the spectral power obtained is shown for specific settings of the two undulator sections. The experiments show

that two-color operation is possible with similar pulse energies of roughly 10  $\mu\text{J}$ . Moreover, the relative pulse energies of the two colors ( $\omega$  vs.  $2\omega$ ) can be tuned in wide limits.

For an extreme case of frequency multiplication, using a short afterburner at for example the third harmonic, the power output is rather small because of the large energy spread generated in the main undulator section. In addition, if the afterburner generates circular polarized light at either the fundamental or odd harmonic, there is the problem that the linearly polarized light from the main undulator section produces a radiation pulse with roughly the same intensity. A proposal to improve this situation is found in [9]. In this scheme, the radiation of the main undulator is suppressed by using an inverse taper. This scheme keeps the bunching to a large extent, but suppresses the radiation and therefore also the energy spread induced during the amplification process. The first experimental demonstration is given in [10]. In the experiment shown in Figure 12, the first 10 undulators of FLASH2 were set up with reversed taper, whereas the last two undulators were used as an afterburner, showing that even though the first 10 undulators did not produce a high radiation intensity, they did produce bunching. In this demonstration experiment, the last two undulators were set to the same wavelength, resulting in an increase in pulse energy exceeding two orders of magnitude.



**Figure 11.** Radiation spectra generated in a frequency doubler experiment at FLASH2 tuned to equal pulse energies for the two wavelength taken with a grating spectrometer [14] in the experimental hall. In blue, the spectral line for the second harmonic at 4.5 nm, and in red, the first harmonic at 9 nm are shown. The electron beam energy in this experiment was 1080 MeV and the bunch charge 300 pC.



**Figure 12.** The figure shows the photon pulse energy measured after the respective undulator in FLASH2. Undulators 1 to 10 were set to reverse tapering while the final two act as an afterburner, leading to an increase in pulse energy by a factor of 200.

#### 4. Future Upgrades

The experimental hall of FLASH2 can accommodate up to six beamlines and experimental stations. Since spring 2016, the beamlines FL24 and FL26 have been open for users. FL24 provides an open port for user-supplied experiments and has been equipped with KB (Kirkpatrick-Baez) focusing optics with bendable mirrors in order to adapt focus size and focal length to user demands. At FL26, the permanent end station REMI, a reaction microscope from the Max-Planck Institute for Nuclear Physics in Heidelberg, has been installed for advanced AMO (atomic, molecular, and optical) physics and molecular femtochemistry experiments [15]. As one of the next beamlines, a new time-compensating monochromator will be installed in the FLASH2 experimental hall. The design for this beamline has recently been finalized after intense discussions with the user community. In addition, it is planned to install a THz undulator at FLASH2 and to integrate a THz streaking station based on a single cycle source in the FLASH2 photon diagnostics section for online pulse duration monitoring.

The FLASH2 FEL control system is not yet completely finished. Regarding the control system, the undulator server, which controls the undulator gaps, phase shifters, and aircoils to correct gap-dependent kicks, now includes the automatic focusing. This means that with one click, one can change the wavelength, keeping the phases, undulator gaps, and focusing at an optimum. However, the undulator length and the starting point for and degree of tapering will also be determined in the near future automatically [16].

The new opportunities with the variable gap undulators in the FLASH2 line outlined above will significantly enhance the FLASH performance for users in the coming years. In the period from 2018 to 2020 we plan to refurbish two accelerator modules in the linac and to install a variable polarization afterburner in FLASH2. Furthermore, a new flexible injector laser for FLASH will be developed which can provide flexible electron bunch patterns at the full repetition rate for simultaneous operation of FLASH1 and FLASH2. In FLASH2, an X-band-deflecting cavity will be installed behind the undulators for advanced diagnostics of SASE pulses. The electron beam diagnostics will be upgraded with particular emphasis on low-charge operation required for the shortest SASE pulses. DESY is also currently in a preparation phase for a long-term upgrade plan of FLASH known as “FLASH2020”. A major part of FLASH2020 will be the exchange of the fixed gap undulators in FLASH1 and the implementation of a new flexible undulator scheme aimed at providing coherent radiation for multi-color experiments over a broad wavelength range.

**Author Contributions:** All authors contributed equally to the work presented in the manuscript

**Conflicts of Interest:** The authors declare no conflict of interest.

#### References

1. Ackermann, W.; Asova, G.; Ayvazyan, V.; Azima, A.; Baboi, N.; Bähr, J.; Balandin, V.; Beutner, B.; Brandt, A.; Bolzmann, A.; et al. Operation of a free-electron laser from the extreme ultraviolet to the water window. *Nat. Photonics* **2007**, *1*, 336.
2. Honkavaara, K.; DESY. Status of the FLASH FEL user facility at DESY. In Proceedings of the FEL2017, Santa Fe, NM, USA, 15 October 2017.
3. Schreiber, S.; Faatz, B. The free-electron laser FLASH. *High Power Laser Sci. Eng.* **2015**, *3*, e20.
4. Faatz, B.; Plönjes, E.; Ackermann, S.; Agababyan, A.; Asgekar, V.; Ayvazyan, V.; Baark, S.; Baboi, N.; Balandin, V.; von Bargen, N.; et al. Simultaneous operation of two soft x-ray free-electron lasers driven by one linear accelerator. *New J. Phys.* **2016**, *18*, 062002.
5. Rönsch-Schulenburg, J.; Faatz, B.; Honkavaara, K.; Kuhlmann, M.; Schreiber, S.; Treusch, R.; Vogt, M. Experience with Multi-Beam and Multi-Beamline FEL-Operation. *J. Phys. Conf. Ser.* **2017**, *874*, 012023.
6. Böedewadt, J.; Aßmann, R.; Ekanayak, N.; Faatz, B.; Hartl, I.; Kazem, M.M.; Laarmann, T.; Lechne, C.; Przystaw, A.; DESY; et al. Experience in Operating sFLASH with High-Gain Harmonic Generation. In Proceedings of the IPAC2017, Copenhagen, Denmark, 14–19 May 2017; p. 2596.

7. Aschikhin, A.; Behrens, C.; Bohlen, S.; Dale, J.; Delbos, N.; di Lucchio, L.; Elsen, E.; Erbe, J.-H.; Felber, M.; Foster, B.; et al. The FLASHForward Facility at DESY. *Nucl. Instrum. Method A* **2016**, *806*, 175.
8. Schneidmiller, E.A.; Yurkov, M.V. Optimum Undulator Tapering of SASE FEL: From the Theory to Experiment. In Proceedings of the 8th International Particle Accelerator Conference (IPAC 2017), Copenhagen, Denmark, 14–19 May 2017; p. 2639.
9. Schneidmiller, E.A.; Yurkov, M.V. Obtaining high degree of circular polarization at x-ray free electron lasers via a reverse undulator tape. *Phys. Rev. ST Accel. Beams* **2013**, *16*, 110702.
10. Schneidmiller, E.A.; Yurkov, M.V. Background-Free Harmonic Production in XFELs via a Reverse Undulator Taper. In Proceedings of the 8th International Particle Accelerator Conference (IPAC 2017), Copenhagen, Denmark, 14–19 May 2017; p. 2618.
11. Kuhlmann, M.; Schneidmiller, E.A.; Yurkov, M.V. Frequency Doubler and Two-Color Mode of Operation at the Free-Electron Laser FLASH2. In Proceedings of the X-ray Free-Electron Lasers: Advances in Source Development and Instrumentation, Prague, Czech Republic, 24–27 April 2017; p. 1023735.
12. Schneidmiller, E.A.; Yurkov, M.V. Harmonic lasing in x-ray free electron lasers. *Phys. Rev. ST Accel. Beams* **2012**, *15*, 080702.
13. Schneidmiller, E.A.; Faatz, B.; Kuhlmann, M.; Roensch-Schulenburg, J.; Schreiber, S.; Tischer, M.; Yurkov, M.V. First operation of a harmonic lasing self-seeded free electron laser. *Phys. Rev. ST Accel. Beams* **2017**, *20*, 020705.
14. Tanikawa, T.; Hage, A.; Kuhlmann, M.; Gonschior, J.; Grunewald, S.; Plönjes, E.; Düsterer, S.; Brenner, G.; Dziarzhytski, S.; Braune, M.; et al. First observation of SASE radiation using the compact wide-spectral-range XUV spectrometer at FLASH2. *Nucl. Instrum. Method A* **2016**, *830*, 170.
15. Plönjes, E.; Faatz, B.; Kuhlmann, M.; Treusch, R. FLASH2: Operation, beamlines, and photon diagnostics. *AIP Conf. Proc.* **2016**, *1741*, 020008.
16. Faatz, B. et al. Automation of FLASH2 operation, in preparation.



© 2017 by the authors. Licensee MDPI, Basel, Switzerland. This article is an open access article distributed under the terms and conditions of the Creative Commons Attribution (CC BY) license (<http://creativecommons.org/licenses/by/4.0/>).